



IPW

IN THE UNITED STATES  
PATENT AND TRADEMARK OFFICE

In re Patent Application of:

<b>Inventor:</b>	Chen et al	<b>Confirmation No:</b>	8388
<b>Serial No.:</b>	10/769,385	<b>Examiner:</b>	Pamela Schwartz
<b>Filed:</b>	Jan 30, 2004	<b>Group Art Unit:</b>	1774
<b>Title:</b>	Surface Modification Of Silica In An Aqueous Environment		

Commissioner for Patents  
P O BOX 1450  
Alexandria VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

In response to your Office Action/Restriction Requirement dated November 25, 2005; Applicants affirm the election with traverse of **Group I (Claims 1-22)** Group II (Claims 23-28) and Group III (Claims 29-37 are hereby withdrawn.

Hewlett-Packard Company  
1000 NE Circle Blvd. m/s 422B  
Corvallis, OR 97330  
(541) 715-4197

Respectfully submitted,

Chen et al

By: W. Bradley Haymond  
W. Bradley Haymond / Reg No: 35,186  
Attorney For Applicants

I hereby certify that this correspondence is being deposited on the date indicated below with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P O Box 1450, Alexandria, VA 22313.

W. Bradley Haymond  
Signature

W. Bradley Haymond  
Typed Name

12-19-05  
Date of Signature